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(54) **OPTICAL SENSING ASSEMBLY AND ENCODER**

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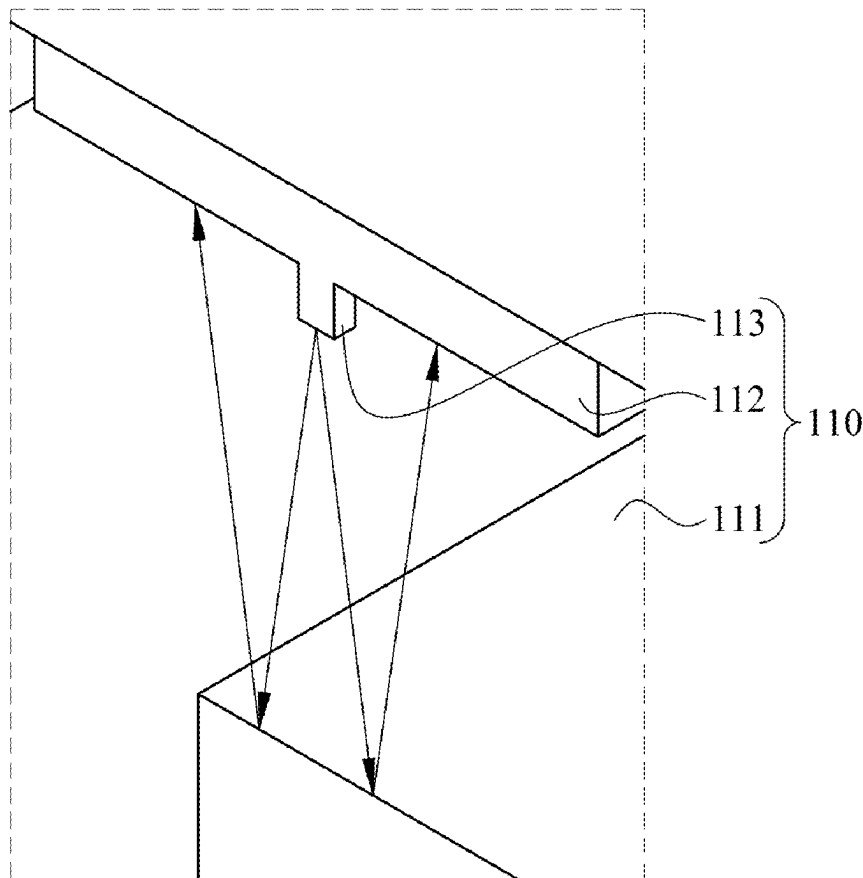
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(57) **ABSTRACT**

An optical sensing assembly includes a scale, a sensor, and a light source. The scale includes a first pattern area and a second pattern area. The first pattern area includes first patterns periodically arranged in the first direction. The second pattern area includes second patterns periodically arranged in the first direction and a second direction. The sensor is configured to move relative to the scale in the first direction and includes a first sensing area, a second sensing area, and a third sensing area. The first sensing area is configured to sense a change of the first pattern area in the first direction. The second sensing area and the third sensing area are configured to sense changes of the second pattern area respectively in the first direction and the second direction. The light source is configured to emit light toward the scale.

100



100

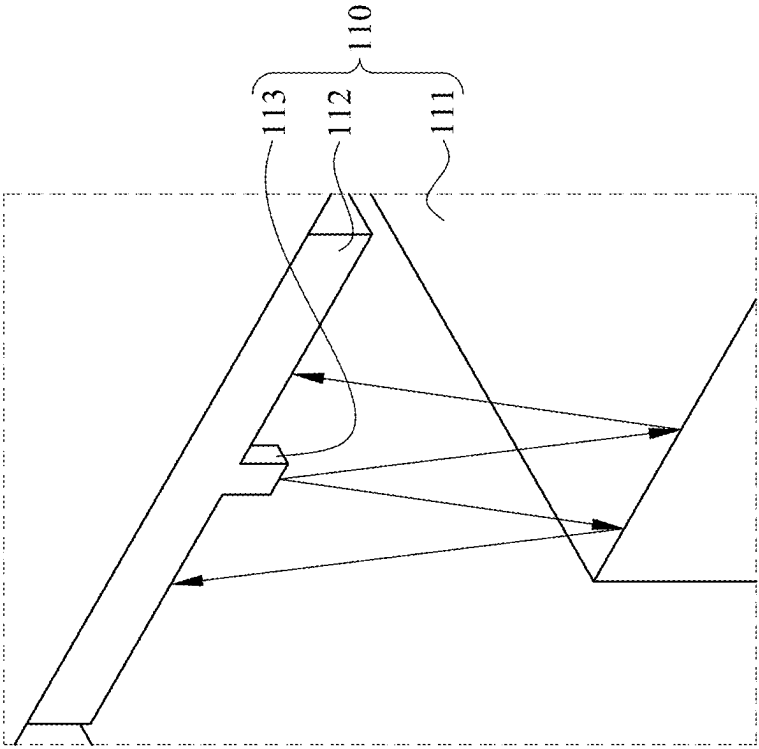


Fig. 1

111

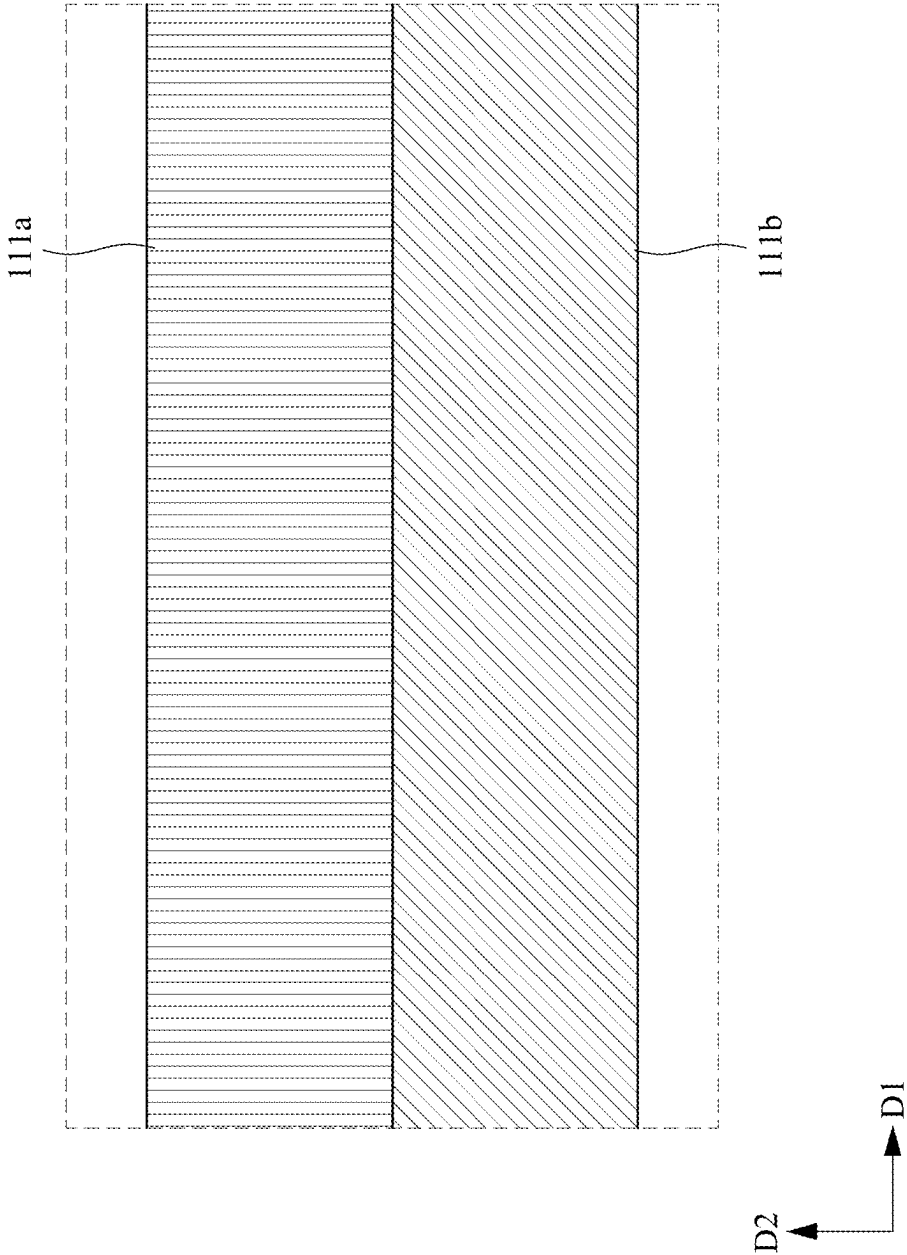


Fig. 2

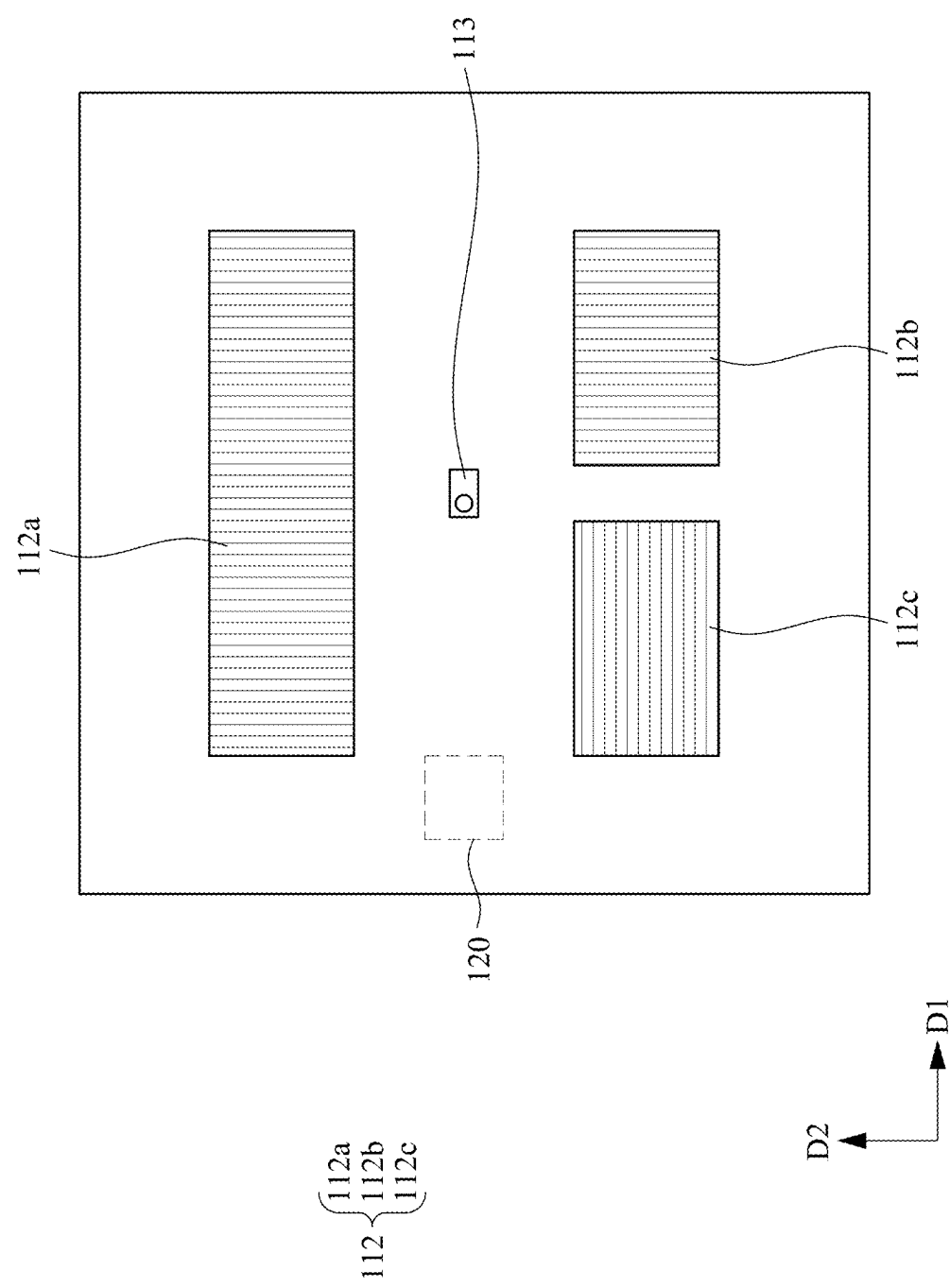


Fig. 3

IIIa

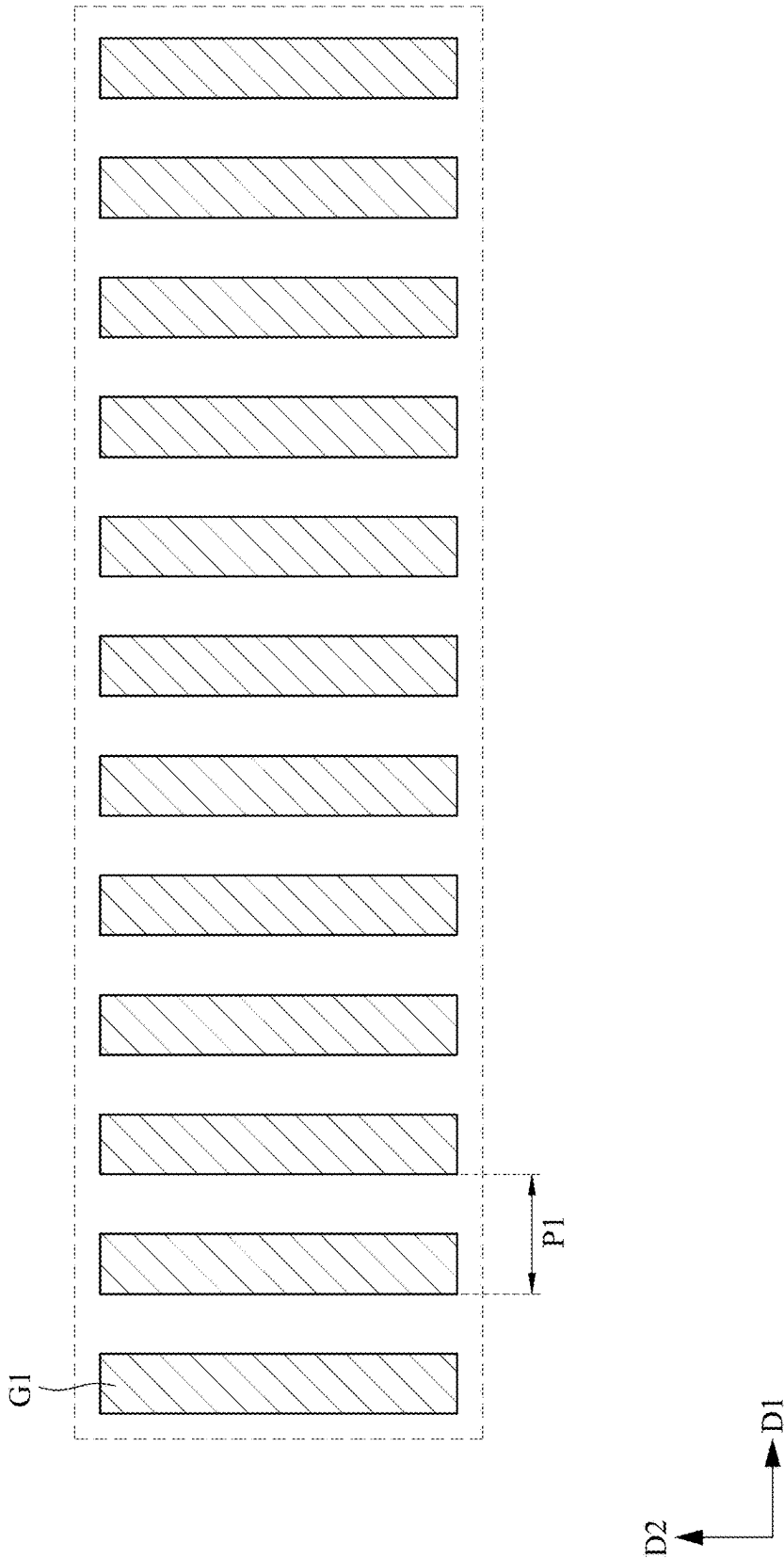


Fig. 4

111b

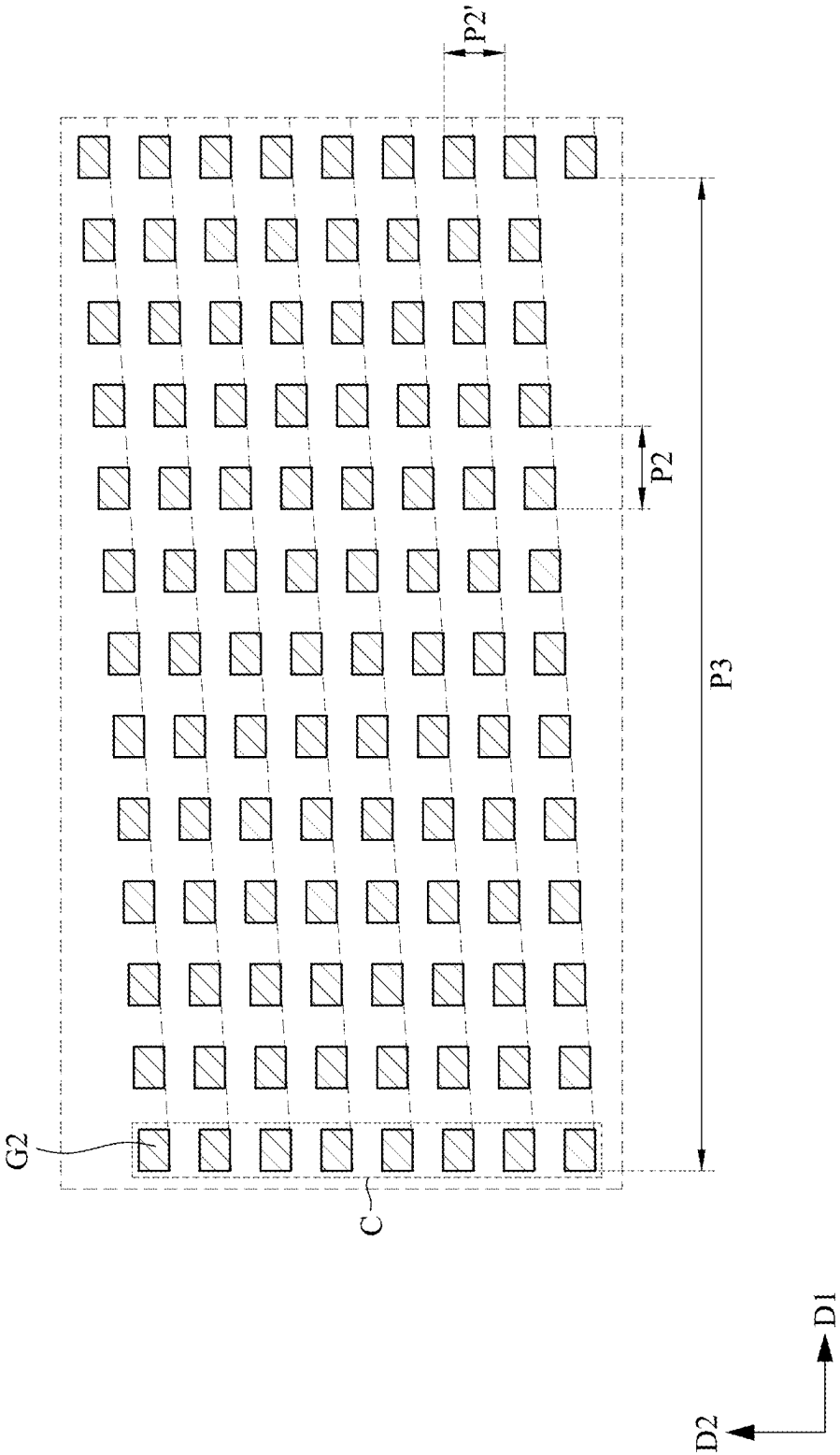


Fig. 5

112a

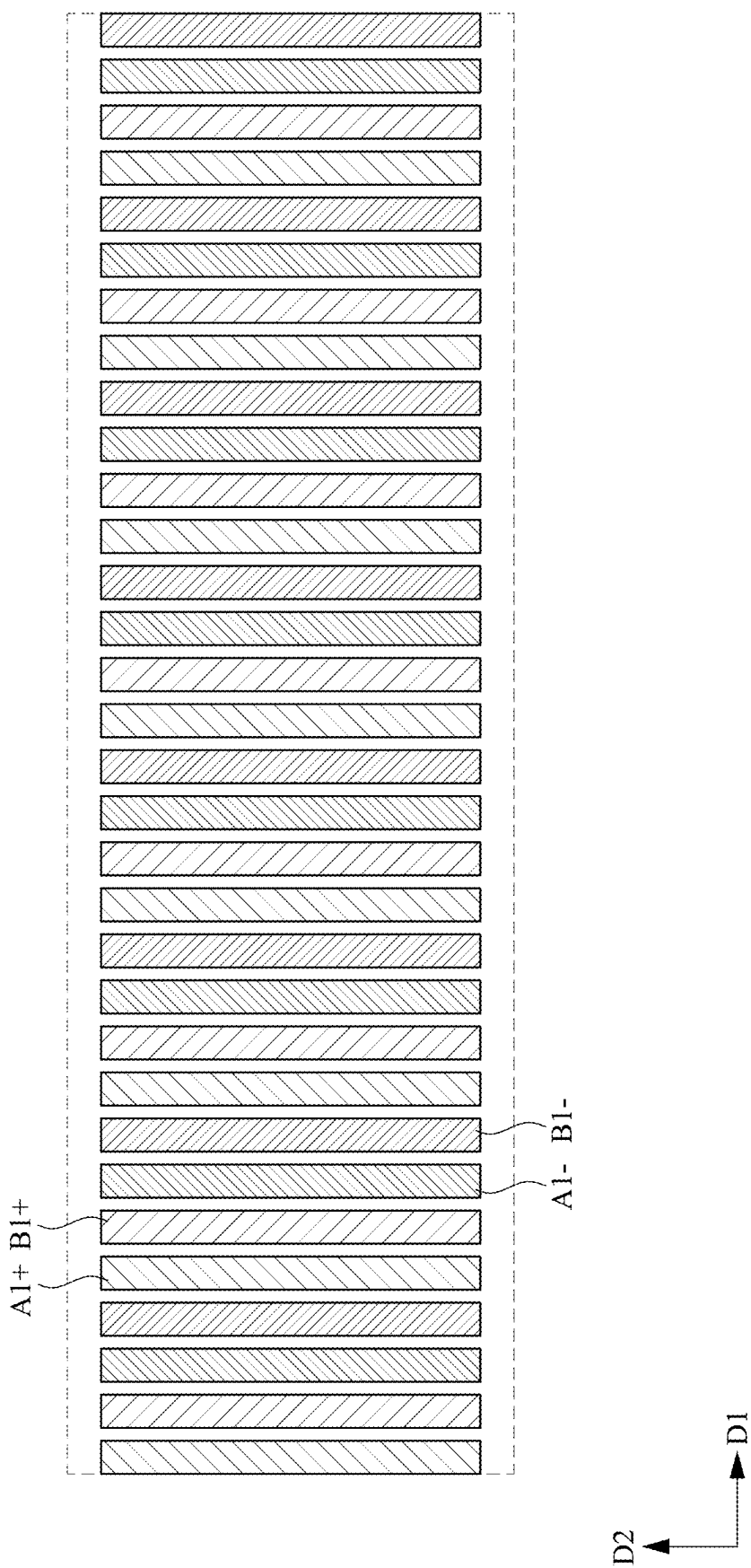


Fig. 6

112b

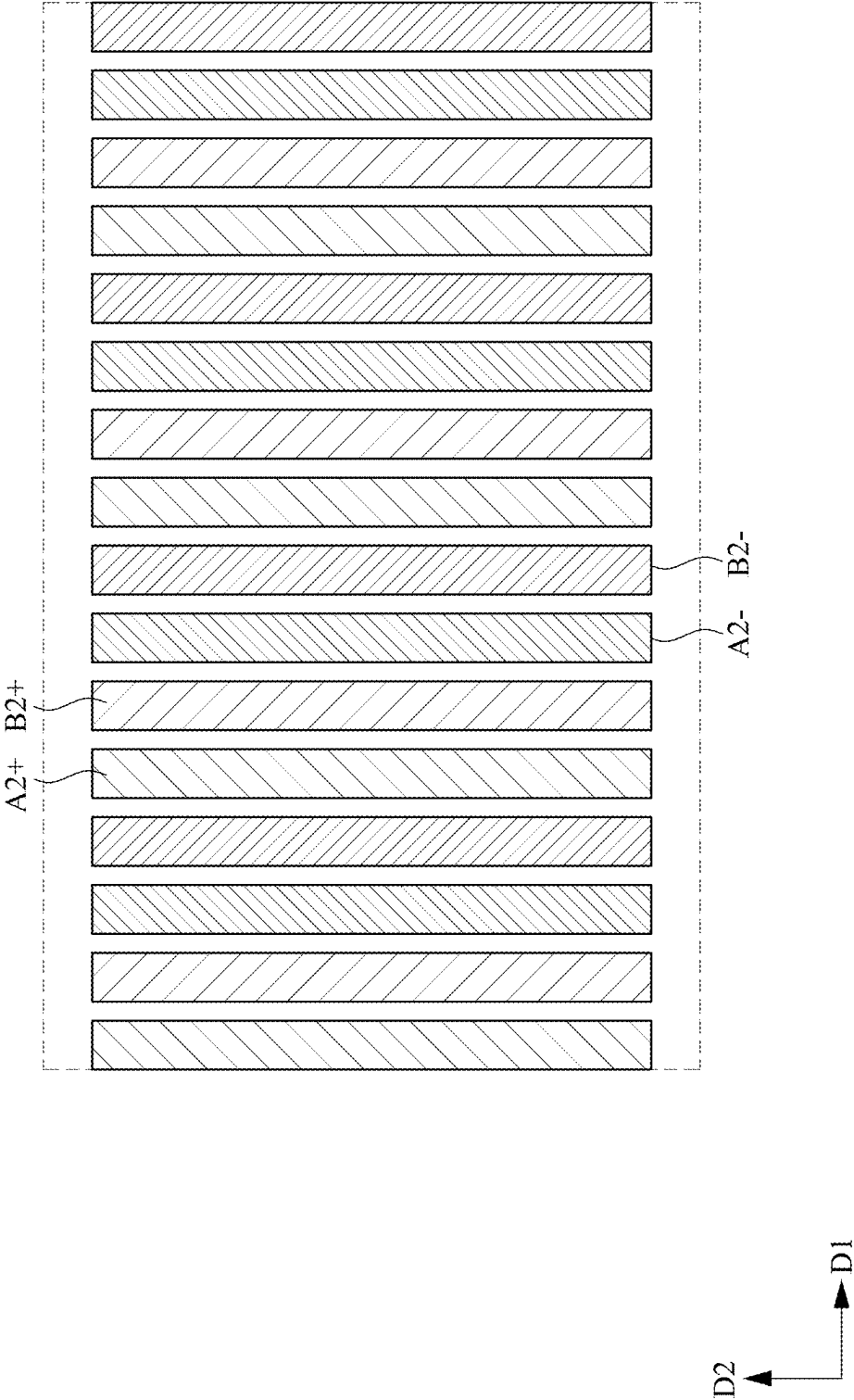


Fig. 7

112c

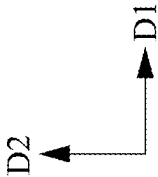
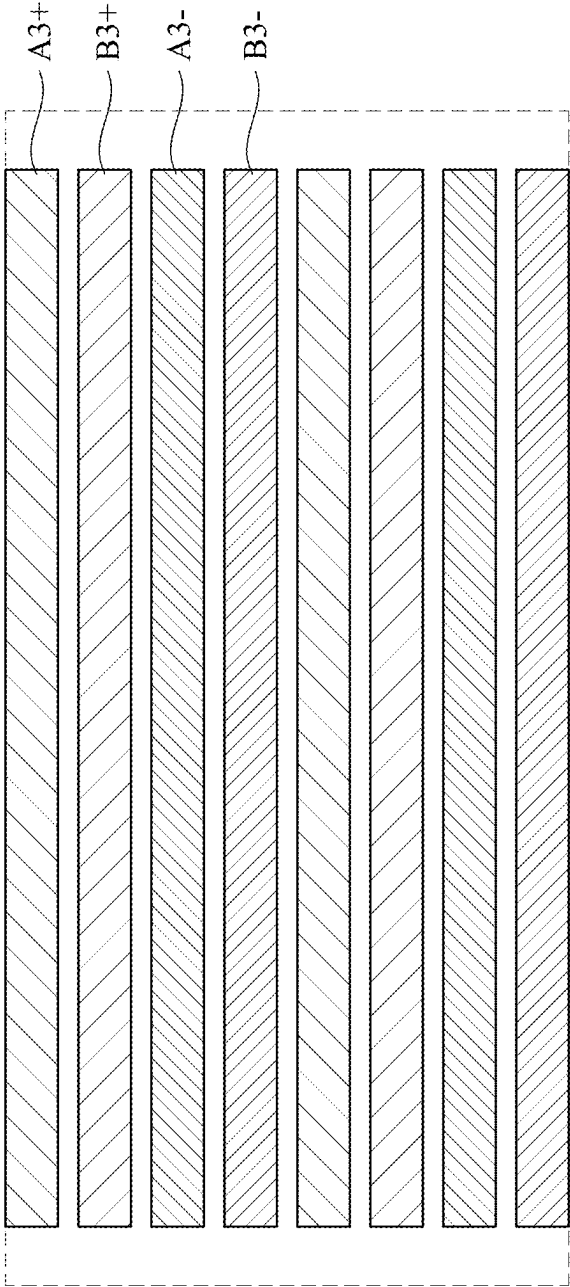


Fig. 8

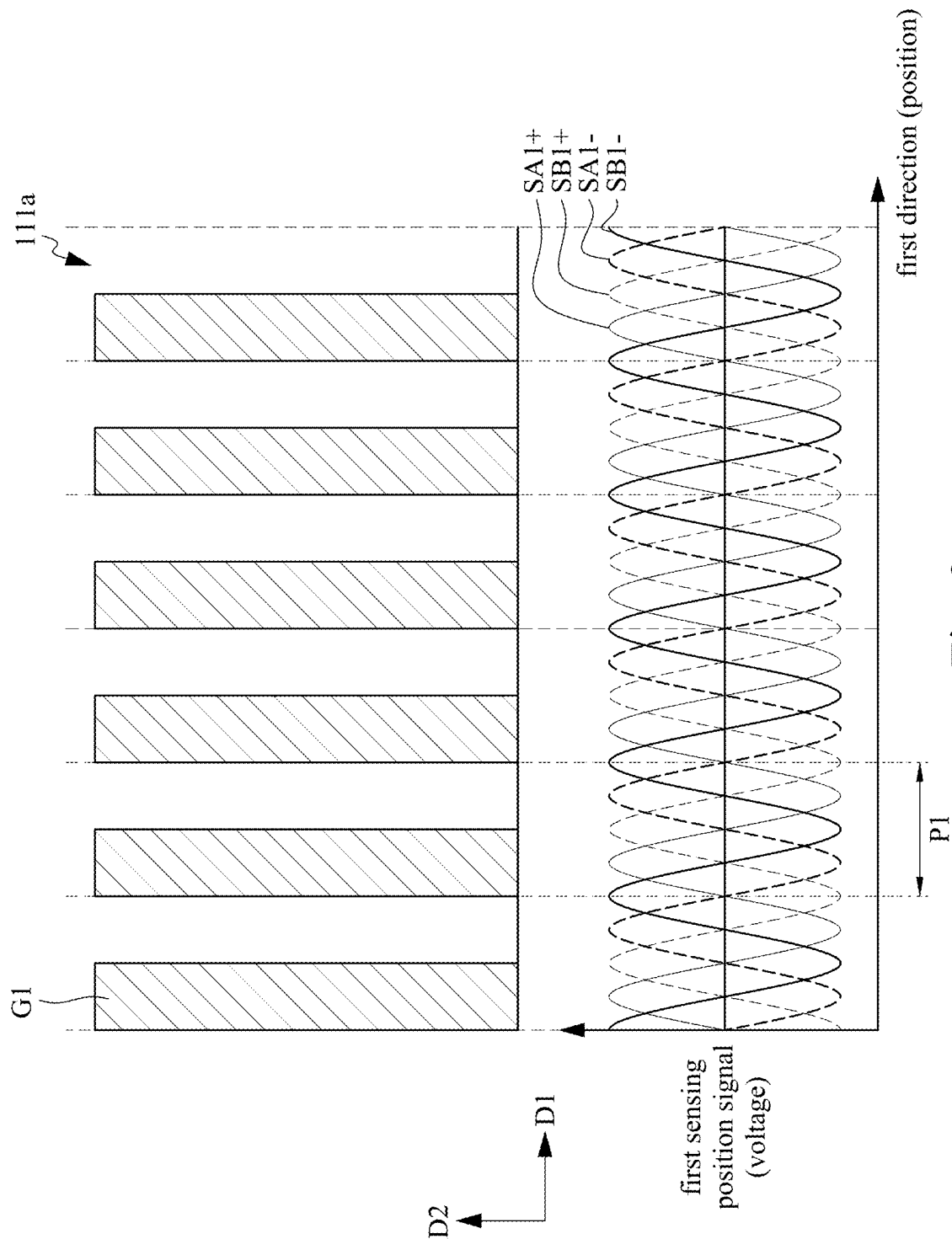


Fig. 9

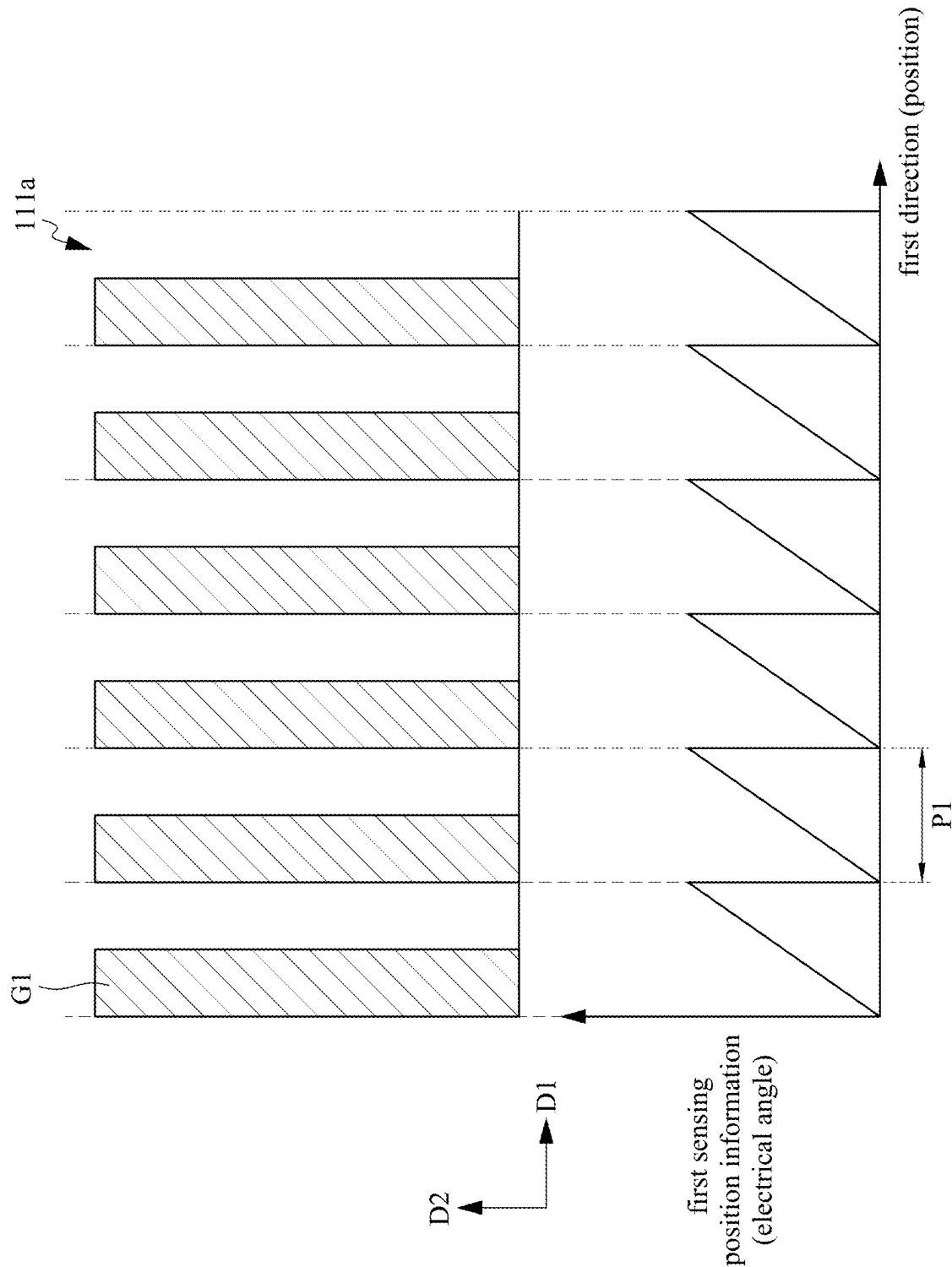


Fig. 10

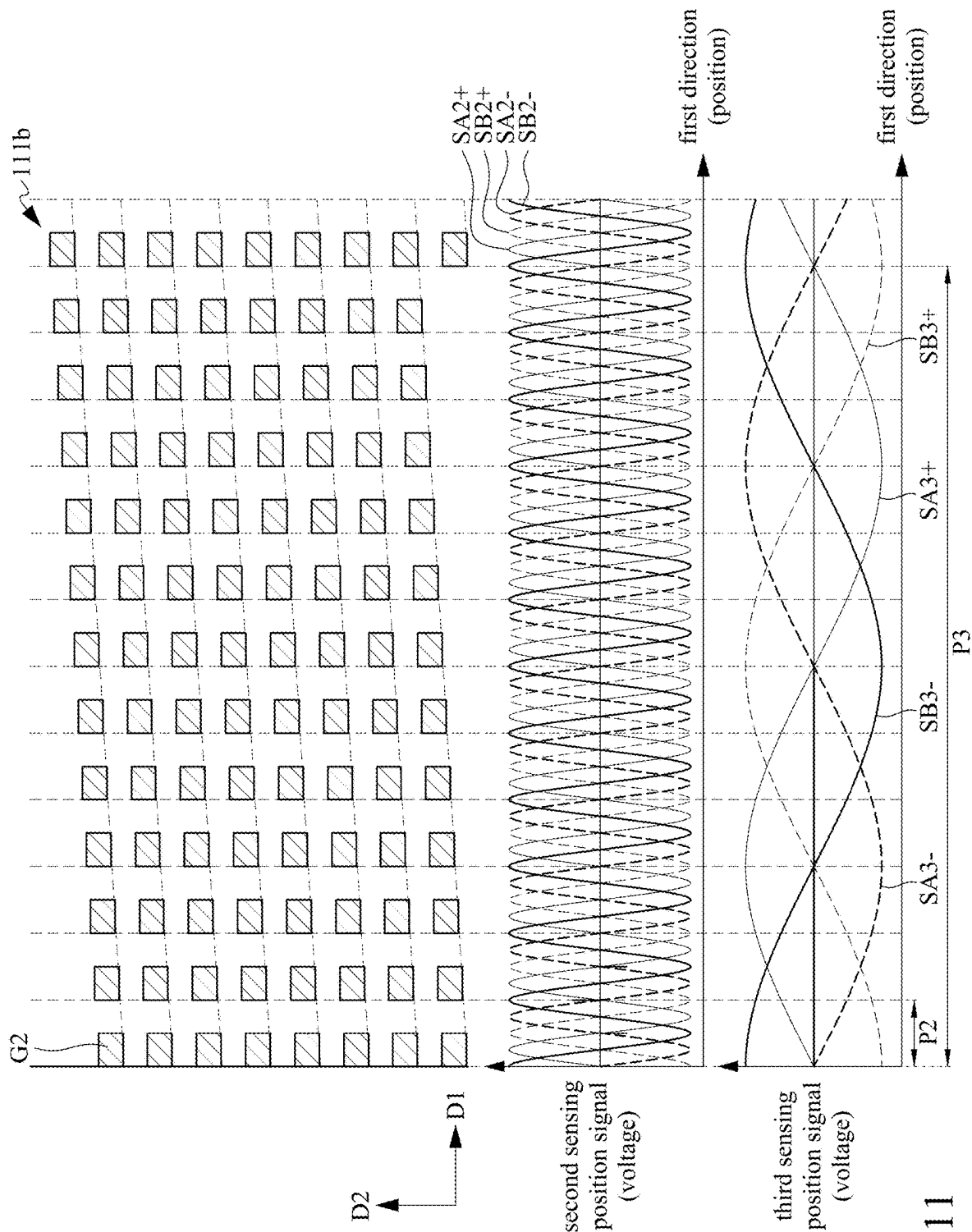
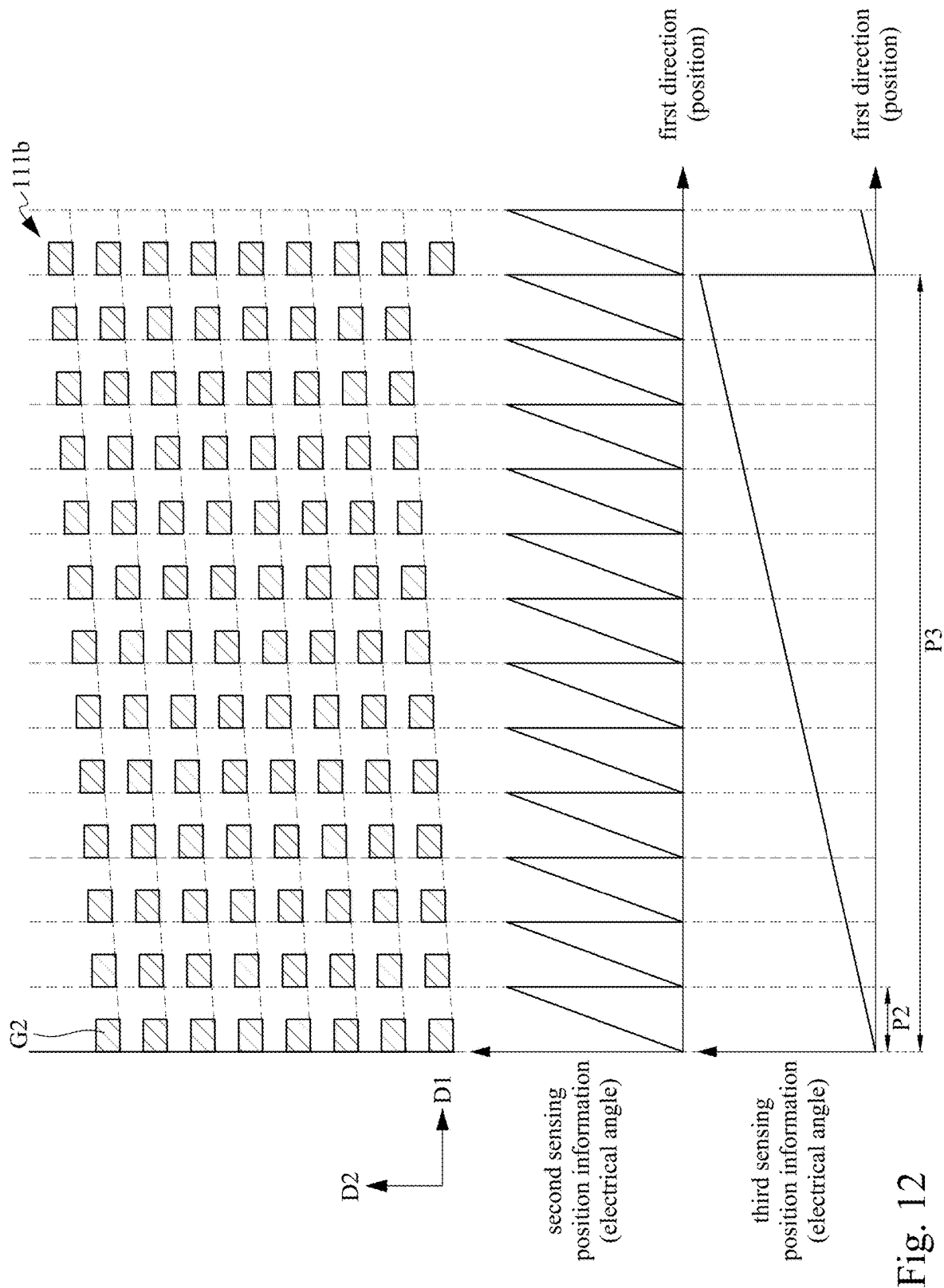


Fig. 11



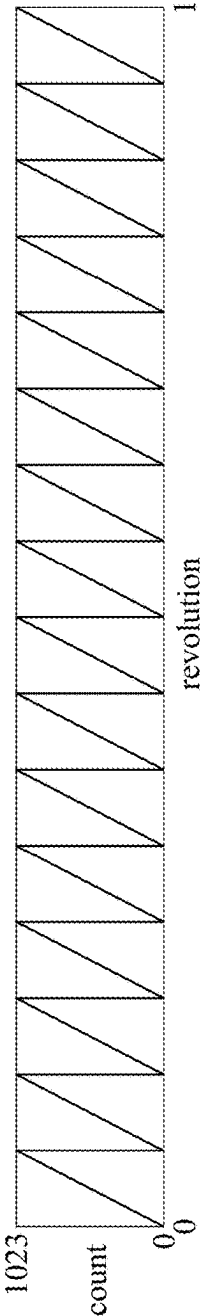


Fig. 13A

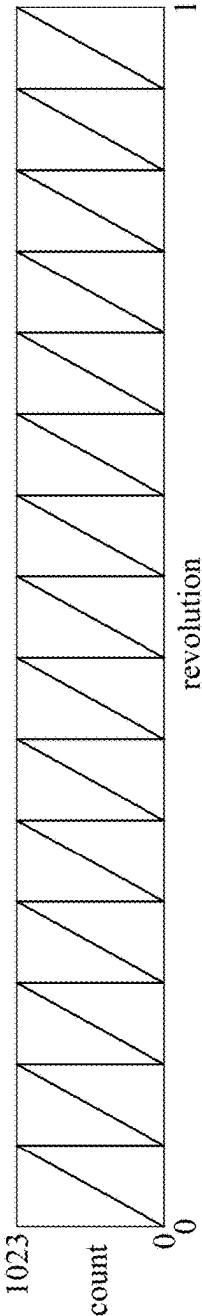


Fig. 13B

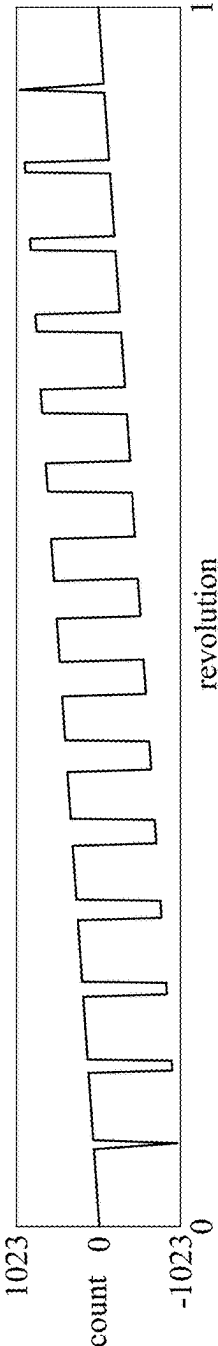


Fig. 13C

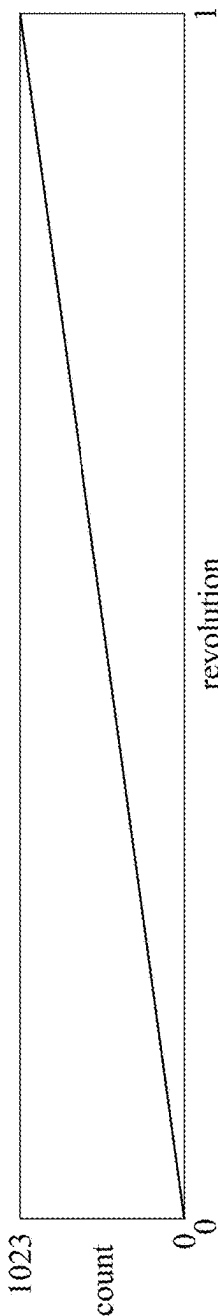


Fig. 13D

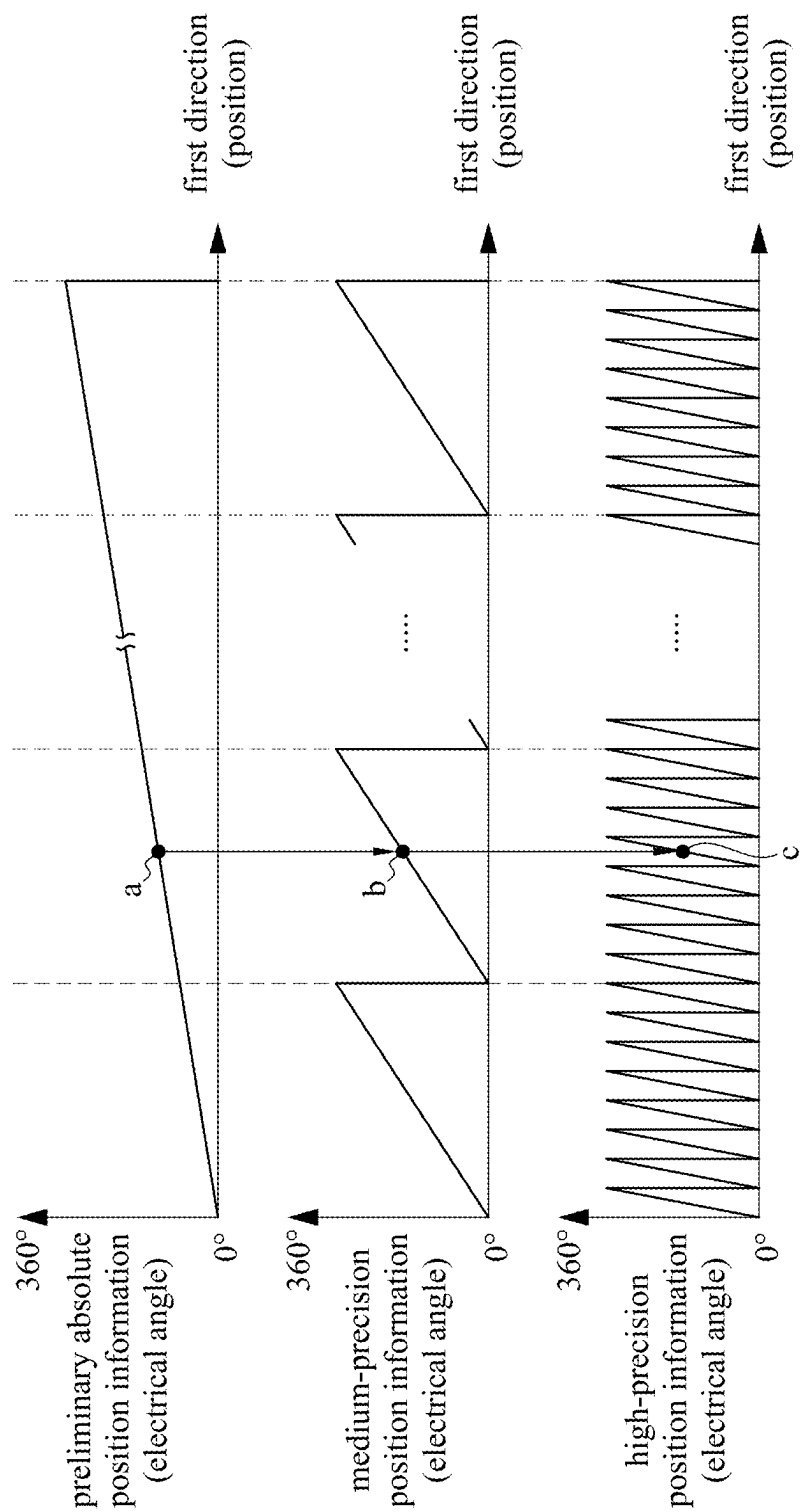


Fig. 14

OPTICAL SENSING ASSEMBLY AND ENCODER

CROSS-REFERENCE TO RELATED APPLICATION

[0001] This application claims priority to China Application Serial Number 202410188329.9, filed Feb. 20, 2024, which is herein incorporated by reference.

BACKGROUND

Technical Field

[0002] The present disclosure relates to an optical sensing assembly and an encoder.

Description of Related Art

[0003] With the advancement of technology, encoder technology is widely used in precision instrument control fields such as motor speed measurement and position detection. For example, absolute encoders can be used to detect the rotational speed, rotation direction, and rotation position of the motor.

[0004] In the conventional technology, optical encoders often use gray code or M code to obtain absolute position information, and their main architectures include light transmitters, light receivers, code disks, and processing circuits. Among them, the light emitter and light receiver of a reflective optical encoder are arranged on the same side relative to the code disk, and the required signal output is obtained by appropriately designing the pattern on the code disk.

[0005] However, since the conventional architectures of encoder and encoding method are very sensitive to positional deviations, the encoders need to be extremely precise in assembly and alignment. Moreover, as the demand for encoder accuracy increases, the sensing area of the corresponding light receiver has also been greatly reduced. As a result, external environmental pollution such as oil, dirt, and particulates will have a serious impact on the sensing of absolute position signals.

[0006] Accordingly, how to develop an optical sensing assembly and an encoder using the same that are different from the previous ones to improve the problems and shortcomings of the conventional technology, to achieve high-precision absolute position sensing, to have a higher ability to withstand environmental pollution, and to enhance the robustness of the encoder becomes an important issue to be solved by those in the industry.

SUMMARY

[0007] An aspect of the disclosure is to provide an optical sensing assembly and an encoder to solve the foregoing problems.

[0008] According to an embodiment of the disclosure, an optical sensing assembly includes a scale, a sensor, and a light source. The scale includes a first pattern area and a second pattern area. The first pattern area includes a plurality of first patterns periodically arranged in a first direction. The second pattern area includes a plurality of second patterns periodically arranged in the first direction and a second direction. The sensor is configured to move relative to the scale in the first direction and includes a first sensing area, a second sensing area, and a third sensing area. The first

sensing area is configured to sense a change of the first pattern area in the first direction. The second sensing area is configured to sense a change of the second pattern area in the first direction. The third sensing area is configured to sense a change of the second pattern area in the second direction. The light source is configured to emit light toward the scale.

[0009] In one or more embodiments of the present disclosure, the second patterns arranged along the first direction are gradually shifted in the second direction.

[0010] In one or more embodiments of the present disclosure, the second patterns are arranged in a plurality of columns. The columns have a pitch in the first direction. The second patterns in each of the columns have another pitch in the second direction. After passing a distance of N times the pitch along the first direction, the columns are gradually shifted in the second direction by a distance of the another pitch. N is an integer greater than 2.

[0011] In one or more embodiments of the present disclosure, when the sensor moves a distance of N times the pitch in the first direction relative to the scale, the second sensing area generates N periodic signals and the third sensing area generates one periodic signal.

[0012] In one or more embodiments of the present disclosure, sensing units of each of the first sensing area, the second sensing area, and the third sensing area are arranged into a phased-array.

[0013] According to an embodiment of the disclosure, an encoder includes an optical sensing assembly and a signal processing unit. The optical sensing assembly includes a scale and a sensor. The scale includes a first pattern area and a second pattern area. The first pattern area includes a plurality of first patterns periodically arranged in a first direction. The second pattern area includes a plurality of second patterns periodically arranged in the first direction and a second direction. The sensor is configured to move relative to the scale in the first direction and includes a first sensing area, a second sensing area, and a third sensing area. The first sensing area is configured to sense a change of the first pattern area in the first direction and accordingly generate a first sensing position signal. The second sensing area is configured to sense a change of the second pattern area in the first direction and accordingly generate a second sensing position signal. The third sensing area is configured to sense a change of the second pattern area in the second direction and accordingly generate a third sensing position signal. The signal processing unit is connected to the sensor and configured to: calculate a first sensing position information, a second sensing position information, and a third sensing position information respectively from the first sensing position signal, the second sensing position signal, and the third sensing position signal; generate a first synthesized position information according to the first sensing position information and the second sensing position information; and generate a second synthesized position information according to the third sensing position information and the first synthesized position information.

[0014] In one or more embodiments of the present disclosure, the second patterns arranged along the first direction are gradually shifted in the second direction.

[0015] In one or more embodiments of the present disclosure, the second patterns are arranged in a plurality of columns. The columns have a pitch in the first direction. The second patterns in each of the columns have another pitch in the second direction. After passing a distance of N times the

pitch along the first direction, the columns are gradually shifted in the second direction by a distance of the another pitch. N is an integer greater than 2.

[0016] In one or more embodiments of the present disclosure, when the sensor moves a distance of N times the pitch in the first direction relative to the scale, the second sensing area generates N periodic signals and the third sensing area generates one periodic signal.

[0017] In one or more embodiments of the present disclosure, sensing units of each of the first sensing area, the second sensing area, and the third sensing area are arranged into a phased-array.

[0018] In one or more embodiments of the present disclosure, the signal processing unit is configured to use the first sensing position information and the second sensing position information to calculate the first synthesized position information based on Vernier effect.

[0019] In one or more embodiments of the present disclosure, the first sensing position information has a first pitch. The second sensing position information has a second pitch. The first synthesized position information has a first synthesized pitch. The second pitch is $(N-2)/(N-1)$ times the first pitch, such that the first synthesized pitch is $(N-2)$ times the first pitch or $(N-1)$ times the second pitch. N is an integer greater than 2.

[0020] In one or more embodiments of the present disclosure, the first sensing position information has N^2 signal cycles within a 360-degree mechanical angle, and the second sensing position information has $N(N-1)$ signal cycles within a 360-degree mechanical angle, such that the first synthesized position information has N signal cycles within a 360-degree mechanical angle. N is an integer greater than 2.

[0021] In one or more embodiments of the present disclosure, the signal processing unit is configured to use the third sensing position information and the first synthesized position information to calculate the second synthesized position information based on Vernier effect.

[0022] In one or more embodiments of the present disclosure, the third sensing position information has a third pitch. The first synthesized position information has a first synthesized pitch. The second synthesized position information has a second synthesized pitch. The first synthesized pitch is $(N-1)/N$ times the third pitch, such that the second synthesized pitch is $(N-1)$ times the third pitch or N times the first synthesized pitch. N is an integer greater than 2.

[0023] In one or more embodiments of the present disclosure, the third sensing position information has $(N-1)$ signal cycles within a 360-degree mechanical angle, and the first synthesized position information has N signal cycles within a 360-degree mechanical angle, such that the second synthesized position information has one signal cycle within a 360-degree mechanical angle. N is an integer greater than 2.

[0024] In one or more embodiments of the present disclosure, the signal processing unit is further configured to: analyze a first position from the second synthesized position information; map the first position to the first synthesized position information or the third sensing position information to analyze a second position; and map the second position to the first sensing position information or the second sensing position information to analyze a third position.

[0025] Accordingly, in the optical sensing assembly of the present disclosure, the scale includes two pattern areas and the sensor includes three sensing areas. One of the sensing areas is configured to sense one of the pattern areas, and the other two of the sensing areas are configured to sense the other one of the pattern areas. Since the scale only includes two pattern areas, the optical sensing assembly only requires a smaller area for sensing, thereby increasing the mechanism assembly margin. Moreover, the sensing units in each of the sensing areas are arranged in a phased array, so the sensing areas have higher resistance to environmental pollution and better assembly positioning margin, thereby enhancing the robustness of the encoder. In addition, the encoding and decoding of the encoder using this optical sensing assembly uses three sets of incremental position signals and the Vernier effect, so high-precision absolute position sensing can be achieved.

[0026] It is to be understood that both the foregoing general description and the following detailed description are by examples, and are intended to provide further explanation of the disclosure as claimed.

BRIEF DESCRIPTION OF THE DRAWINGS

[0027] The disclosure can be more fully understood by reading the following detailed description of the embodiment, with reference made to the accompanying drawings as follows:

[0028] FIG. 1 is a partial perspective view of an encoder according to an embodiment of the present disclosure;

[0029] FIG. 2 is a partial schematic diagram of a scale in FIG. 1;

[0030] FIG. 3 is a schematic diagram of a sensor, a light source, and a signal processing unit in FIG. 1;

[0031] FIG. 4 is a partial schematic diagram of a first pattern area of the scale according to an embodiment of the present disclosure;

[0032] FIG. 5 is a partial schematic diagram of a second pattern area of the scale according to an embodiment of the present disclosure;

[0033] FIG. 6 is a partial schematic diagram of a first sensing area of the sensor according to an embodiment of the present disclosure;

[0034] FIG. 7 is a partial schematic diagram of a second sensing area of the sensor according to an embodiment of the present disclosure;

[0035] FIG. 8 is a partial schematic diagram of a third sensing area of the sensor according to an embodiment of the present disclosure;

[0036] FIG. 9 is a schematic diagram illustrating a first sensing position signal obtained by sensing the first pattern area using the first sensing area;

[0037] FIG. 10 is a schematic diagram illustrating a first sensing position information calculated from the first sensing position signal;

[0038] FIG. 11 is a schematic diagram illustrating a second sensing position signal and a third sensing position signal obtained by sensing the second pattern area using the second sensing area and the third sensing area respectively;

[0039] FIG. 12 is a schematic diagram illustrating a second sensing position information and a third sensing position information calculated from the second sensing position signal and the third sensing position signal respectively;

[0040] FIG. 13A is a schematic diagram of a 16-period signal;

[0041] FIG. 13B is a schematic diagram of a 15-period signal;

[0042] FIG. 13C is a schematic diagram of a difference signal between the 16-period signal and the 15-period signal;

[0043] FIG. 13D is a schematic diagram of the difference signal in FIG. 13C in the form of unsigned 10-bit data; and

[0044] FIG. 14 is a schematic diagram illustrating a position information obtained by a position detection method of the encoder according to an embodiment of the present disclosure.

DETAILED DESCRIPTION

[0045] Reference will now be made in detail to the present embodiments of the disclosure, examples of which are illustrated in the accompanying drawings. Wherever possible, the same reference numbers are used in the drawings and the description to refer to the same or like parts. However, specific structural and functional details disclosed herein are merely representative for purposes of describing example embodiments, and thus may be embodied in many alternate forms and should not be construed as limited to only example embodiments set forth herein. Therefore, it should be understood that there is no intent to limit example embodiments to the particular forms disclosed, but on the contrary, example embodiments are to cover all modifications, equivalents, and alternatives falling within the scope of the disclosure.

[0046] Reference is made to FIG. 1. FIG. 1 is a partial perspective view of an encoder 100 according to an embodiment of the present disclosure. As shown in FIG. 1, in the present embodiment, the encoder 100 includes an optical sensing assembly 110. The optical sensing assembly 110 includes a scale 111, a sensor 112, and a light source 113. The scale 111 and the sensor 112 are disposed relative to each other and can be displaced relative to each other. For example, the scale 111 can move linearly or rotate relative to the sensor 112. The light source 113 is disposed on a side of the sensor 112 facing the scale 111 and is configured to emit light toward the scale 111. The sensor 112 is configured to receive and sense the light reflected by the scale 111.

[0047] Reference is made to FIG. 2 and FIG. 3. FIG. 2 is a partial schematic diagram of the scale 111 in FIG. 1. FIG. 3 is a schematic diagram of the sensor 112, the light source 113, and a signal processing unit 120 in FIG. 1. As shown in FIG. 2 and FIG. 3, in the present embodiment, the scale 111 includes a first pattern area 111a and a second pattern area 111b. The first pattern area 111a and the second pattern area 111b extend in a first direction D1 and are arranged in a second direction D2. The first direction D1 and the second direction D2 are perpendicular to each other. The sensor 112 is configured to move relative to the scale 111 in the first direction D1 and includes a first sensing area 112a, a second sensing area 112b, and a third sensing area 112c. The first sensing area 112a is configured to sense a change of the first pattern area 111a in the first direction D1. The second sensing area 112b is configured to sense a change of the second pattern area 111b in the first direction D1. The third sensing area 112c is configured to sense a change of the second pattern area 111b in the second direction D2.

[0048] In some embodiments where the encoder 100 is linear, the first direction D1 is X direction and the second direction D2 is Y direction. In some embodiments where the encoder 100 is rotary, the first direction D1 is the circumferential (Θ) direction and the second direction D2 is the radial (R) direction.

[0049] Reference is made to FIG. 4. FIG. 4 is a partial schematic diagram of a first pattern area 111a of the scale 111 according to an embodiment of the present disclosure. As shown in FIG. 4, in the present embodiment, the first pattern area 111a of the scale 111 includes a plurality of first patterns G1 periodically arranged in the first direction D1. The shape of the first patterns G1 is strip shape. The first patterns G1 extend in the second direction D2 and are sequentially arranged in the first direction D1. The first patterns G1 have a first pitch P1 in the first direction D1. In some embodiments, the scale 111 adopts a reflective structure, so the first patterns G1 are high-reflective areas, and the area outside the first patterns G1 is a low-reflective area. In some embodiments, the scale 111 adopts a transmissive structure, so the first patterns G1 are high light-transmitting areas, and the area outside the first patterns G1 is a low light-transmitting area.

[0050] Reference is made to FIG. 5. FIG. 5 is a partial schematic diagram of a second pattern area 111b of the scale 111 according to an embodiment of the present disclosure. As shown in FIG. 5, in the present embodiment, the second pattern area 111b of the scale 111 includes a plurality of second patterns G2 periodically arranged in the first direction D1 and the second direction D2. Specifically, the second patterns G2 are arranged in a plurality of columns C. The columns C have a second pitch P2 in the first direction D1. The second patterns G2 in each of the columns C have another pitch P2' in the second direction D2. In other words, the second patterns G2 of the second pattern area 111b constitute a two-dimensional pattern.

[0051] In the present embodiment, the shape of each of the second patterns G2 is square, but the disclosure is not limited thereto. In some embodiments, the scale 111 adopts a reflective structure, so the second patterns G2 are high-reflective areas, and the area outside the second patterns G2 is a low-reflective area. In some embodiments, the scale 111 adopts a transmissive structure, so the second patterns G2 are high light-transmitting areas, and the area outside the second patterns G2 is a low light-transmitting area.

[0052] In particular, the second patterns G2 arranged along the first direction D1 are gradually shifted in the second direction D2. Specifically, as shown in FIG. 5, after passing a distance of N times the second pitch P2 along the first direction D1, the columns C are gradually shifted in the second direction D2 by a distance of the another pitch P2'. N is an integer greater than 2. In other words, each of the second patterns G2 has a third pitch P3 in the first direction D1, and the third pitch P3 is N times the second pitch P2. Correspondingly, when the sensor 112 moves a distance of N times the second pitch P2 in the first direction D1 relative to the scale 111, the second sensing area 112b generates N periodic signals and the third sensing area 112c generates one periodic signal.

[0053] Through the aforementioned structural configurations, during the relative movement of the sensor 112 and the scale 111 in the first direction D1, the sensor 112 can use the first sensing area 112a to sense the first pattern area 111a and use the second sensing area 112b and the third sensing area

112c to simultaneously sense the second pattern area **111b**. Since the scale **111** only includes two pattern areas, the optical sensing assembly **110** only requires a smaller area for sensing, thereby increasing the mechanical assembly margin.

[0054] In some embodiments, **N** is an integer greater than 2. For example, as shown in FIG. 5, **N** is 12 (That is, the columns **C** will be gradually shifted by a distance of one pitch **P2'** in the second direction **D2** after passing a distance of 12 times the second pitch **P2** along the first direction **D1**), but the disclosure is not limited thereto.

[0055] Reference is made to FIG. 6, FIG. 7, and FIG. 8. FIG. 6 is a partial schematic diagram of the first sensing area **112a** of the sensor **112** according to an embodiment of the present disclosure. FIG. 7 is a partial schematic diagram of the second sensing area **112b** of the sensor **112** according to an embodiment of the present disclosure. FIG. 8 is a partial schematic diagram of the third sensing area **112c** of the sensor **112** according to an embodiment of the present disclosure. As shown in FIGS. 6 to 8, the first sensing area **112a** includes a plurality of sensing units **A1+**, **B1+**, **A1-**, **B1-** arranged into a phased-array. The second sensing area **112b** includes a plurality of sensing units **A2+**, **B2+**, **A2-**, **B2-** arranged into a phased-array. The third sensing area **112c** includes a plurality of sensing units **A3+**, **B3+**, **A3-**, **B3-** arranged into a phased-array. Specifically, the sensing units **A1+**, **B1+**, **A1-**, **B1-** of the first sensing area **112a** adopt a periodic phase array arrangement in the first direction **D1**. That is, the interleaved arrangement of the sensing unit **A1+**, the sensing unit **B1+**, the sensing unit **A1-**, and the sensing unit **B1-** in sequence is repeated for a plurality of cycles. The sensing units **A2+**, **B2+**, **A2-**, **B2-** of the second sensing area **112b** adopt a periodic phase array arrangement in the first direction **D1**. That is, the interleaved arrangement of the sensing unit **A2+**, the sensing unit **B2+**, the sensing unit **A2-**, and the sensing unit **B2-** in sequence is repeated for a plurality of cycles. The sensing units **A3+**, **B3+**, **A3-**, **B3-** of the third sensing area **112c** adopt a periodic phase array arrangement in the second direction **D2**. That is, the interleaved arrangement of the sensing unit **A3+**, the sensing unit **B3+**, the sensing unit **A3-**, and the sensing unit **B3-** in sequence is repeated for a plurality of cycles. By adopting the phased-array arrangement, the first sensing area **112a**, the second sensing area **112b**, and the third sensing area **112c** can have higher resistance to environmental pollution and better assembly positioning margin, thereby enhancing the robustness of the encoder **100**.

[0056] Reference is made to FIG. 9. FIG. 9 is a schematic diagram illustrating a first sensing position signal obtained by sensing the first pattern area **111a** using the first sensing area **112a**. As shown in FIG. 9, in the present embodiment, after sensing a change of the first pattern area **111a** in the first direction **D1**, the first sensing area **112a** will correspondingly generate the first sensing position signal. In detail, the sensing units **A1+**, **B1+**, **A1-**, **B1-** of the first sensing area **112a** will generate first sensing position signals **SA1+**, **SB1+**, **SA1-**, **SB1-** respectively.

[0057] As shown in FIG. 3, in the present embodiment, the encoder **100** further includes a signal processing unit **120** (shown in dashed lines). The signal processing unit **120** is connected to the sensor **112** and configured to process the first sensing position signals **SA1+**, **SB1+**, **SA1-**, **SB1-** generated by the first sensing area **112a**. In the present embodiment, the signal processing unit **120** is integrated

with the sensor **112**, but the disclosure is not limited thereto. In practical applications, the signal processing unit **120** and the sensor **112** may not be integrated together and connected through additional components.

[0058] Reference is made to FIG. 10. FIG. 10 is a schematic diagram illustrating a first sensing position information calculated from the first sensing position signal. In the present embodiment, the signal processing unit **120** is configured to calculate the first sensing position information (as shown in FIG. 10) from the first sensing position signals **SA1+**, **SB1+**, **SA1-**, **SB1-** (as shown in FIG. 9). For example, the first sensing position information can be calculated through an arctangent function (i.e., **ATAN** function). The first sensing position information also has the first pitch **P1**.

[0059] Reference is made to FIG. 11. FIG. 11 is a schematic diagram illustrating a second sensing position signal and a third sensing position signal obtained by sensing the second pattern area **111b** using the second sensing area **112b** and the third sensing area **112c** respectively. As shown in FIG. 11, in the present embodiment, after sensing a change of the second pattern area **111b** in the first direction **D1**, the second sensing area **112b** will correspondingly generate the second sensing position signal **SA2+**, **SB2+**, **SA2-**, **SB2-**. After sensing a change of the second pattern area **111b** in the second direction **D2**, the third sensing area **112c** will correspondingly generate the third sensing position signal **SA3+**, **SB3+**, **SA3-**, **SB3-**.

[0060] Reference is made to FIG. 12. FIG. 12 is a schematic diagram illustrating a second sensing position information and a third sensing position information calculated from the second sensing position signal and the third sensing position signal respectively. In the present embodiment, the signal processing unit **120** is further configured to calculate the second sensing position information (as shown in FIG. 12) from the second sensing position signals **SA2+**, **SB2+**, **SA2-**, **SB2-** (as shown in FIG. 11). For example, the second sensing position information can be calculated through an arctangent function. The second sensing position information also has the second pitch **P2**. In addition, the signal processing unit **120** is further configured to calculate the third sensing position information (as shown in FIG. 12) from the third sensing position signals **SA3+**, **SB3+**, **SA3-**, **SB3-** (as shown in FIG. 11). For example, the third sensing position information can be calculated through an arctangent function. The third sensing position information also has the third pitch **P3**.

[0061] In the present embodiment, the signal processing unit **120** is further configured to generate a first synthesized position information according to the first sensing position information and the second sensing position information, and generate a second synthesized position information according to the third sensing position information and the first synthesized position information. Specifically, the signal processing unit **120** is configured to use the first sensing position information and the second sensing position information to calculate the first synthesized position information based on Vernier effect. The signal processing unit **120** is further configured to use the third sensing position information and the first synthesized position information to calculate the second synthesized position information based on Vernier effect. The principle of Vernier effect is briefly described as follows.

[0062] Reference is made to FIG. 13A, FIG. 13B, FIG. 13C, and FIG. 13D. FIG. 13A is a schematic diagram of a 16-period signal. FIG. 13B is a schematic diagram of a 15-period signal. FIG. 13C is a schematic diagram of a difference signal between the 16-period signal and the 15-period signal. FIG. 13D is a schematic diagram of the difference signal in FIG. 13C in the form of unsigned 10-bit data. As shown in FIGS. 13A to 13D, after subtracting the 15-period signal in FIG. 13B from the 16-period signal in FIG. 13A, the difference signal in FIG. 13C can be obtained. Further, by converting the difference signal in FIG. 13C into the unsigned 10-bit data form, the single period signal shown in FIG. 13D can be obtained.

[0063] In some embodiments where the encoder 100 is linear, the first synthesized position information has a first synthesized pitch PS1. The second pitch P2 of the second sensing position information is $(N-2)/(N-1)$ times the first pitch P1 of the first sensing position information, such that the first synthesized pitch PS1 is $(N-2)$ times the first pitch P1 or $(N-1)$ times the second pitch P2. N is an integer greater than 2.

[0064] In some embodiments where the encoder 100 is linear, the second synthesized position information has a second synthesized pitch PS2. The first synthesized pitch PS1 is $(N-1)/N$ times the third pitch P3, such that the second synthesized pitch PS2 is $(N-1)$ times the third pitch P3 or N times the first synthesized pitch PS1. N is an integer greater than 2.

[0065] For example, under the conditions that N is 33, the first pitch P1 is 64 μm , the second pitch P2 is 62 μm , and the third pitch P3 is 2,046 μm , the signal processing unit 120 can generate the first synthesized position information with the first synthesized pitch PS1 of 1,984 μm and the second synthesized position information with the second synthesized pitch PS2 of 65,472 μm .

[0066] For example, under the conditions that N is 65, the first pitch P1 is 64 μm , the second pitch P2 is 63 μm , and the third pitch P3 is 4,095 μm , the signal processing unit 120 can generate the first synthesized position information with the first synthesized pitch PS1 of 4,032 μm and the second synthesized position information with the second synthesized pitch PS2 of 262,080 μm .

[0067] In some embodiments where the encoder 100 is rotary, the first sensing position information has N^2 signal cycles within a 360-degree mechanical angle, and the second sensing position information has $N(N-1)$ signal cycles within a 360-degree mechanical angle, such that the first synthesized position information has N signal cycles within a 360-degree mechanical angle. N is an integer greater than 2.

[0068] In some embodiments where the encoder 100 is rotary, the third sensing position information has $(N-1)$ signal cycles within a 360-degree mechanical angle, and the first synthesized position information has N signal cycles within a 360-degree mechanical angle, such that the second synthesized position information has one signal cycle within a 360-degree mechanical angle. N is an integer greater than 2.

[0069] For example, under the condition that N is 32 and the first sensing position information, the second sensing position information, and the third sensing position information respectively have 1,024, 992, and 31 signal cycles within a 360-degree mechanical angle, the signal processing unit 120 can generate the first synthesized position infor-

mation having 32 signal cycles within a 360-degree mechanical angle and the second synthesized position information having one signal cycle within a 360-degree mechanical angle.

[0070] For example, under the condition that N is 50 and the first sensing position information, the second sensing position information, and the third sensing position information respectively have 2,500, 2,450, and 49 signal cycles within a 360-degree mechanical angle, the signal processing unit 120 can generate the first synthesized position information having 50 signal cycles within a 360-degree mechanical angle and the second synthesized position information having one signal cycle within a 360-degree mechanical angle.

[0071] It should be noted that the second synthesized position information analyzed by the signal processing unit 120 can be used as preliminary absolute position information. The third sensing position information or the first synthesized position information analyzed by the signal processing unit 120 can be used as medium-precision position information. The first sensing position information or the second sensing position information can be used as high-precision position information.

[0072] Reference is made to FIG. 14. FIG. 14 is a schematic diagram illustrating a position information obtained by a position detection method of the encoder 100 according to an embodiment of the present disclosure. As shown in FIG. 14, in the present embodiment, the signal processing unit 120 is further configured to analyze a first position a from the second synthesized position information (i.e., the preliminary absolute position information). The signal processing unit 120 is further configured to map the first position a to the first synthesized position information or the third sensing position information (i.e., the medium-precision position information) to analyze a second position b, which is the second cycle position as shown in the figure. The signal processing unit 120 is further configured to map the second position b to the first sensing position information or the second sensing position information (i.e., the high-precision position information) to analyze a third position c, which is the fifth cycle position as shown in the figure. The third position c is a high-precision absolute position. This progressive position analyzing step maps a lower-precision initial absolute position to a medium-precision incremental position, and then maps a medium-precision incremental position to the high-precision incremental position, such that the analyzed position information is a high-precision absolute position. In this way, the encoder 100 of the present embodiment can realize high-precision absolute position sensing.

[0073] According to the foregoing recitations of the embodiments of the disclosure, it can be seen that in the optical sensing assembly of the present disclosure, the scale includes two pattern areas and the sensor includes three sensing areas. One of the sensing areas is configured to sense one of the pattern areas, and the other two of the sensing areas are configured to sense the other one of the pattern areas. Since the scale only includes two pattern areas, the optical sensing assembly only requires a smaller area for sensing, thereby increasing the mechanism assembly margin. Moreover, the sensing units in each of the sensing areas are arranged in a phased array, so the sensing areas have higher resistance to environmental pollution and better assembly positioning margin, thereby enhancing the robust-

ness of the encoder. In addition, the encoding and decoding of the encoder using this optical sensing assembly uses three sets of incremental position signals and the Vernier effect, so high-precision absolute position sensing can be achieved.

[0074] Although the present disclosure has been described in considerable detail with reference to certain embodiments thereof, other embodiments are possible. Therefore, the spirit and scope of the appended claims should not be limited to the description of the embodiments contained herein.

[0075] It will be apparent to those skilled in the art that various modifications and variations can be made to the structure of the present disclosure without departing from the scope or spirit of the disclosure. In view of the foregoing, it is intended that the present disclosure cover modifications and variations of this disclosure provided they fall within the scope of the following claims.

What is claimed is:

1. An optical sensing assembly, comprising:
 - a scale comprising:
 - a first pattern area comprising a plurality of first patterns periodically arranged in a first direction; and
 - a second pattern area comprising a plurality of second patterns periodically arranged in the first direction and a second direction;
 - a sensor configured to move relative to the scale in the first direction and comprising:
 - a first sensing area configured to sense a change of the first pattern area in the first direction;
 - a second sensing area configured to sense a change of the second pattern area in the first direction; and
 - a third sensing area configured to sense a change of the second pattern area in the second direction; and
 - a light source configured to emit light toward the scale.
2. The optical sensing assembly of claim 1, wherein the second patterns arranged along the first direction are gradually shifted in the second direction.
3. The optical sensing assembly of claim 2, wherein the second patterns are arranged in a plurality of columns, the columns have a pitch in the first direction, the second patterns in each of the columns have another pitch in the second direction, and after passing a distance of N times the pitch along the first direction, the columns are gradually shifted in the second direction by a distance of the another pitch, wherein N is an integer greater than 2.
4. The optical sensing assembly of claim 3, wherein when the sensor moves a distance of N times the pitch in the first direction relative to the scale, the second sensing area generates N periodic signals and the third sensing area generates one periodic signal.
5. The optical sensing assembly of claim 1, wherein sensing units of each of the first sensing area, the second sensing area, and the third sensing area are arranged into a phased-array.
6. An encoder, comprising:
 - an optical sensing assembly comprising:
 - a scale comprising:
 - a first pattern area comprising a plurality of first patterns periodically arranged in a first direction; and
 - a second pattern area comprising a plurality of second patterns periodically arranged in the first direction and a second direction;

- a sensor configured to move relative to the scale in the first direction and comprising:

- a first sensing area configured to sense a change of the first pattern area in the first direction and accordingly generate a first sensing position signal;

- a second sensing area configured to sense a change of the second pattern area in the first direction and accordingly generate a second sensing position signal; and

- a third sensing area configured to sense a change of the second pattern area in the second direction and accordingly generate a third sensing position signal; and

- a signal processing unit connected to the sensor and configured to:

- calculate a first sensing position information, a second sensing position information, and a third sensing position information respectively from the first sensing position signal, the second sensing position signal, and the third sensing position signal;

- generate a first synthesized position information according to the first sensing position information and the second sensing position information; and

- generate a second synthesized position information according to the third sensing position information and the first synthesized position information.

7. The encoder of claim 6, wherein the second patterns arranged along the first direction are gradually shifted in the second direction.

8. The encoder of claim 7, wherein the second patterns are arranged in a plurality of columns, the columns have a pitch in the first direction, the second patterns in each of the columns have another pitch in the second direction, and after passing a distance of N times the pitch along the first direction, the columns are gradually shifted in the second direction by a distance of the another pitch, wherein N is an integer greater than 2.

9. The encoder of claim 8, wherein when the sensor moves a distance of N times the pitch in the first direction relative to the scale, the second sensing area generates N periodic signals and the third sensing area generates one periodic signal.

10. The encoder of claim 6, wherein sensing units of each of the first sensing area, the second sensing area, and the third sensing area are arranged into a phased-array.

11. The encoder of claim 6, wherein the signal processing unit is configured to use the first sensing position information and the second sensing position information to calculate the first synthesized position information based on Vernier effect.

12. The encoder of claim 11, wherein the first sensing position information has a first pitch, the second sensing position information has a second pitch, the first synthesized position information has a first synthesized pitch, wherein the second pitch is $(N-2)/(N-1)$ times the first pitch, such that the first synthesized pitch is (N-2) times the first pitch or (N-1) times the second pitch, wherein N is an integer greater than 2.

13. The encoder of claim 11, where the first sensing position information has N2 signal cycles within a 360-degree mechanical angle, and the second sensing position information has N (N-1) signal cycles within a 360-degree mechanical angle, such that the first synthesized position

information has N signal cycles within a 360-degree mechanical angle, wherein N is an integer greater than 2.

14. The encoder of claim **6**, wherein the signal processing unit is configured to use the third sensing position information and the first synthesized position information to calculate the second synthesized position information based on Vernier effect.

15. The encoder of claim **14**, wherein the third sensing position information has a third pitch, the first synthesized position information has a first synthesized pitch, the second synthesized position information has a second synthesized pitch, wherein the first synthesized pitch is $(N-1)/N$ times the third pitch, such that the second synthesized pitch is $(N-1)$ times the third pitch or N times the first synthesized pitch, wherein N is an integer greater than 2.

16. The encoder of claim **14**, wherein the third sensing position information has $(N-1)$ signal cycles within a 360-

degree mechanical angle, and the first synthesized position information has N signal cycles within a 360-degree mechanical angle, such that the second synthesized position information has one signal cycle within a 360-degree mechanical angle, wherein N is an integer greater than 2.

17. The encoder of claim **6**, wherein the signal processing unit is further configured to:

analyze a first position from the second synthesized position information;

map the first position to the first synthesized position information or the third sensing position information to analyze a second position; and

map the second position to the first sensing position information or the second sensing position information to analyze a third position.

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